Absorber and gain chip optimization to improve performance from a passively modelocked electrically pumped vertical external cavity surface emitting laser

C. A. Zaugg, 1,a) S. Gronenborn, 2 H. Moench, 2 M. Mangold, 1 M. Miller, 2 U. Weichmann, 2 W. P. Pallmann, 1 M. Golling, 1 B. W. Tilma, 1 and U. Keller 1

1Department of Physics, Institute for Quantum Electronics, ETH Zürich, 8093 Zürich, Switzerland
2Philips Technologie GmbH Photonics Aachen, Steinbachstrasse 15, 52074 Aachen, Germany
3Philips Technologie GmbH U-L-M Photonics, Lise-Meitner-Strasse 13, 89081 Ulm, Germany

(Received 21 February 2014; accepted 18 March 2014; published online 28 March 2014)

We present an electrically pumped vertical-external-cavity surface-emitting laser (EP-VECSEL) modelocked with a semiconductor saturable absorber mirror (SESAM) with significantly improved performance. In different cavity configurations, we present the shortest pulses (2.5 ps), highest average output power (53.2 mW), highest repetition rate (18.2 GHz), and highest peak power (4.7 W) to date. The simple and low-cost concept of EP-VECSELs is very attractive for mass-market applications such as optical communication and clocking. The improvements result from an optimized gain chip from Philips Technologie GmbH and a SESAM, specifically designed for EP-VECSELs. For the gain chip, we found a better trade-off between electrical and optical losses with an optimized doping scheme in the substrate to increase the average output power. Furthermore, the device’s bottom contact diameter (60 μm) is smaller than the oxide aperture diameter (100 μm), which favors electro-optical conversion into a TEM 00 mode. Compared to optically pumped VECSELs we have to increase the field enhancement in the active region of an EP-VECSEL which requires a SESAM with lower saturation fluence and higher modulation depth for modelocking. We therefore used a resonant quantum well SESAM with a 3.5-pair dielectric top-coating (SiN x and SiO 2) to enhance the field in the absorber at the lasing wavelength of 980 nm. The absorption bandedge at room temperature is detuned (965 nm) compared to the resonance (980 nm), which enables temperature-tuning of the modulation depth and saturation fluence from approximately 2.5% up to 15% and from 20 μJ/cm 2 to 1.1 μJ/cm 2, respectively. © 2014 Author(s). All article content, except where otherwise noted, is licensed under a Creative Commons Attribution 3.0 Unported License. [http://dx.doi.org/10.1063/1.4870048]

Optically pumped (OP) vertical-external-cavity surface-emitting lasers (OP-VECSELs), 1 also referred to as OP semiconductor disk lasers (OP-SDL), have evolved to powerful laser sources offering a continuous wave (cw) average output power beyond the 100 W level (multimode). 2 Passively modelocked with a semiconductor saturable absorber mirror (SESAM) 3 makes VECSELs a compact, 4,5 low-noise 6,7 emitter of ultrashort pulses in a repetition rate range from <100 MHz 4 to 50 GHz 5 (fundamental modelocking) or even 175 GHz in harmonic modelocking. 9 Sub-100 fs pulses in burst operation, 10 107 fs in fundamental modelocked operation with a few mW of average power, 11 and multi-Watt level average output power with a few hundred fs-pulses 12–14 have been demonstrated recently for wavelengths around 1 μm. As semiconductor gain allows for band-gap engineering, modelocking was demonstrated in various other wavelength ranges, e.g., in red, 15,16 at 1.2 μm 17 or at 2 μm. 18

Since both the VECSEL gain chip and the saturable absorber are based on semiconductor materials, they can be combined into one chip, which is referred to as the MIXSEL (modelocked integrated-external-cavity surface-emitting laser). 19 Record high performance has been reported from optically pumped MIXSELs, e.g., the highest average power of 6.4 W with picosecond pulses, 20 femtosecond pulses, 21 fundamental modelocking from 5 to >100 GHz repetition rates, 22,23 record low timing jitter performance. 24 With the MIXSEL, modelocked SDLs made a significant improvement in compactness and complexity. 23

A practical alternative approach for more compact VECSELs is to use electrical pumping (EP-VECSELs), 24–26 which can intrinsically be implemented in semiconductor lasers. This reduces the complexity, the footprint, and the costs of these lasers drastically. Compared to vertical surface-emitting lasers (VCSELs), 27,28 EP-VECSELs offer the possibility for power scaling 25,29 while maintaining higher beam quality and brightness. However, compared to OP-VECELs, the performance of EP-VECSELs is limited by the fundamental trade-off between electrical and optical losses: higher doping reduces the electrical resistance and therefore leads to a lower thermal load, thus increasing the maximum output power; on the other hand, the higher doping induces a higher free-carrier absorption (FCA) thus limiting the output power. 25 Nevertheless, up to 500 mW in TEM 00 operation was demonstrated from EP-VECSELs (i.e., the NECSEL from Novalux) in 2003. 24 With the same chips, first passive modelocking results were presented with up to 40 mW in 57-ps pulses, 30 15-ps pulses with some tens of mW and a repetition rate of up to 15 GHz. 31 In 2012, we
presented sub-10-ps pulses in collaboration with Philips Technologie GmbH. After pulses as short as 6.3 ps with an average output power of 6.2 mW or a peak power of more than 1 W were demonstrated with chips designed, grown, and fabricated at ETH.29

The previous results indicated that a better trade-off between the electrical and optical properties of the gain chip combined with an improved SESAM could potentially generate both shorter pulse durations and higher average output powers. Based on our prior experience, we used an improved SESAM, specifically designed for EP-VECSELs, to obtain modelocking with the new gain chip from Philips Technologie GmbH, optimized for fundamental-transverse mode at high output power (up to 90 mW). As a result, we set benchmarks to the peak and average output power, pulse duration and repetition rate from modelocked EP-VECSELs: pulses as short as 2.5 ps, average output power up to 53.2 mW, and repetition rates of up to 18.2 GHz were obtained with a SESAM modelocked EP-VECSEL in different cavity configurations. As the electrical pumping scheme allows for extremely compact packaging with footprints down to a few mm² for the 18-GHz cavity, passively modelocked EP-VECSELs could be considered as interesting candidates for mass-market applications such as optical communication, sampling, and clocking.

We use the latest generation EP-VECSEL gain chip fabricated by Philips Technologie GmbH based on the concept and design presented in 2014 and similar to the ones previously used for modelocking. The basic structure chosen for this gain chip is referred to as a bottom emitter, meaning that the light is emitted through the substrate of the semiconductor layer stack. This processing scheme allows for bonding the bottom mirror directly onto the heat sink and thus enables an efficient thermal management, which is crucial for high-power operation. After processing, the EP-VECSEL gain chip consists of the following elements (listed from bottom to top): An AlN heat spreader; a bottom contact with a diameter (BCD) of 60 µm; an AlGaAs 37-pair p-doped distributed Bragg reflector (p-DBR) serving as bottom mirror; the active region consisting of 3 InGaAs quantum wells (QWs) embedded in GaAs; an intermediate n-doped DBR with 11 pairs; an oxide aperture with a diameter of 100 µm; the substrate thinned down to 100 µm; a top ring electrode and a single-layer dielectric anti-reflection (AR) coating. The two major improvements (compared to the Philips chips previously presented) can be summarized as follows. First, an optimized doping scheme is implemented leading to a better trade-off between electrical and optical losses. In particular, the n-doping of the substrate is reduced from 11 × 10¹⁶ cm⁻³ to 5.7 × 10¹⁶ cm⁻³ resulting in an increase of both the average power and efficiency of more than 10%. Second, the BCD (60 µm) was chosen to be smaller than the oxide aperture (100 µm), which strongly confines the current injection profile in the center, whereas the vertical waveguide due to the refractive index change of the semiconductor with SiNx and SiO₂ using a plasma enhanced chemical vapor deposition (PECVD) reactor. At 25°C, the absorption of the QW finds its maximum at 965 nm, shifting with approximately 0.32 nm/K. The DBR is designed for 960 nm with a of the uncoated SESAM of 0.34 (normalized to the incoming field intensity of 1). To reduce the and enhance the ΔR, we coated the semiconductor with SiNₓ and SiO₂ using a plasma enhanced chemical vapor deposition (PECVD) reactor. To achieve a maximum resonance at λ ≈ 980 nm (the laser’s operation wavelength), we chose 7 layers with thicknesses as follows (starting from the semiconductor side): 135.2 nm SiNx followed by 3 pairs of λ/4-layers of SiO₂ (168.9 nm) and SiNₓ (128.7 nm). This layer sequence leads to a theoretical of 6.5, i.e., an enhancement of 20 compared to the as-grown structure. Since the layers grown by PECVD suffer from thickness variations of up to 5% per individual layer, the resulting of SiNₓ is difficult to estimate. However, the crucial parameters ΔR and are experimentally accessible with our high precision non-linear reflectivity measurement setup. We use a commercial modelocked Ti:Sapphire laser emitting 110 fs-pulses at a center wavelength of 980 nm to characterize the SESAM. At 25°C, the top-coated SESAM exhibits a ΔR = 2.9% and an ΔF = 3.1 μJ/cm². With increasing temperature, the QW’s absorption overlaps more and more with the
The mode size radii were designed to be approximately 50 \mu m on the gain chip and slightly smaller, i.e., 30 to 45 \mu m on the SESAM in order to enhance the saturation and thus exploit the optimum modulation. The exact beam waists are difficult to estimate due to a strong, pump-current dependent thermal lens. But since we aligned the cavity simultaneously for modelocking performance and beam quality, the thermal lens is optimally compensated for each configuration. For the Z-cavity, we used a folding mirror with a ROC of 15 mm at a distance of \approx 14 mm from the SESAM and \approx 19 mm from the gain chip, respectively. The OC with a ROC of 38 mm was placed \approx 35 mm from the gain chip, leading to a total cavity length of \approx 68 mm and a pulse repetition rate of 2.2 GHz. We estimate the mode size radii in this case to be 50 \mu m on the gain chip and 35 \mu m on the SESAM. An AR-coated, 20 \mu m thick fused silica etalon was used for polarization control, except in the 18-GHz cavity.

We achieved stable fundamental modelocking using a variety of laser configurations. Figure 2 shows a measurement set of the highest average output power of 53.2 mW emitted from the 9.2-GHz cavity using an OC of 11% (ROC 15 mm) at a pump current of 355 mA. The microwave spectrum detected with a fast photodiode is shown in Fig. 2(a). With an autocorrelator we measured a pulse duration of 2.9 ps, see Fig. 2(b), and verified fundamental modelocking (inset). The pulses are nearly transform limited and centered around 981 nm as measured with an optical signal analyzer shown in Fig. 2(c). The heat sink temperature of the gain chip and the SESAM was kept at 3 °C and 32 °C (see Fig. 1), respectively.

Using the OC with a ROC of 10 mm (OC transmission of 5%) in a shorter cavity enabled modelocking at 18.2 GHz with 10.1 mW of average output power at an injection current of 265 mA. Clean microwave spectra in a wide and narrow span are shown in Figs. 3(a) and 3(b), respectively. The pulse duration was measured to be 9.7 ps as shown in the autocorrelation of the pulse train in Fig. 3(c). No background is present between two pulses, thus confirming fundamental modelocking with clearly separated pulses. For this laser, the gain chip and SESAM heat sink temperatures were stabilized at 3 °C and at 25 °C (see Fig. 1), respectively. We emphasize that the volume containing the essential elements for this cavity (i.e., OC mirror with mount, gain chip on heatsink, and SESAM on mount) is only \sim 3 \times 3 \times 2 cm^3.

![FIG. 1. Temperature dependent SESAM parameters: saturation fluences \( F_{sat} \) (blue triangles, left axis) and modulation depths \( \Delta R \) (green circles, right axis) measured at 980 nm with 110 fs pulses.](image1)

![FIG. 2. SESAM modelocked EP-VECSEL with highest average output power of 53.2 mW. (a) Microwave spectrum of the pulse train in a wide span and zoomed in around the fundamental pulse repetition frequency of 9.23 GHz (inset). (b) Autocorrelation (blue) and sech^2-fit (red dashed) revealing a pulse duration of 2.9 ps. We verified fundamental modelocking with a longer time delay (inset). (c) Optical spectrum showing a clean and a close to transform-limited spectral width. (TBP: time-bandwidth product.)](image2)
The optical spectrum is centered around 981 nm (Fig. 4(b)) with a peak power of 4.7 W, and the highest repetition rate (18.2 GHz). The gain chip, optimized for high TEM$_{00}$ power, enabled the increase of average output power. In addition, we used an optimized SESAM with the correctly adapted nonlinear properties, i.e., a low $F_{\text{sat}}$ and a high $\Delta R$, both finely adjusted by temperature. But as much as this SESAM is essential to explain the short pulses, it is not sufficient. As reported recently for OP-VECSELs, the total group delay dispersion (GDD) per cavity round-trip needs to be managed carefully. However, for resonant gain chips and SESAMs, GDD can neither be calculated nor measured very precisely. Therefore, we can only assume that by aligning and tuning the EP-VECSEL for the shortest pulses (e.g., cavity alignment, injection current, and chip temperatures), a laser cavity configuration with a small absolute GDD value was found, thus explaining the low chirp (Fig. 4(a)). In this case, the pulse duration was only restricted by the gain bandwidth, which is limited by the high finesse of the Fabry-Pérot cavity formed by the resonant sub-cavity around the active region. By reducing the reflectivity of the intermediate n-DBR, the gain bandwidth can be broadened, but only at the expense of a lower small-signal gain. Therefore, a trade-off between average output power and pulse duration is always present in an EP-VECSEL.

In conclusion, we presented improved modelocking results of EP-VECSELs in different cavity configurations, i.e., the shortest pulses (2.5 ps), highest average (53.2 mW), and peak power (4.7 W), and the highest repetition rate (18.2 GHz). The gain chip, optimized for high TEM$_{00}$ power, enabled the increase of average output power. In addition, we used an optimized SESAM with the correctly adapted nonlinear properties, i.e., a low $F_{\text{sat}}$ and a high $\Delta R$, both finely adjusted by temperature. But as much as this SESAM is essential to explain the short pulses, it is not sufficient. As reported recently for OP-VECSELs, the total group delay dispersion (GDD) per cavity round-trip needs to be managed carefully. However, for resonant gain chips and SESAMs, GDD can neither be calculated nor measured very precisely. Therefore, we can only assume that by aligning and tuning the EP-VECSEL for the shortest pulses (e.g., cavity alignment, injection current, and chip temperatures), a laser cavity configuration with a small absolute GDD value was found, thus explaining the low chirp (Fig. 4(a)). In this case, the pulse duration was only restricted by the gain bandwidth, which is limited by the high finesse of the Fabry-Pérot cavity formed by the resonant sub-cavity around the active region. By reducing the reflectivity of the intermediate n-DBR, the gain bandwidth can be broadened, but only at the expense of a lower small-signal gain. Therefore, a trade-off between average output power and pulse duration is always present in an EP-VECSEL.

The authors acknowledge support of the technology and cleanroom facility FIRST of ETH Zurich for advanced micro- and nanotechnology. This work was financed by the Swiss Confederation Program Nano-Tera.ch, which was scientifically evaluated by the Swiss National Science Foundation (SNSF).


### TABLE I. Overview of the results presented in this paper.

<table>
<thead>
<tr>
<th>$P_{\text{avg}}$ (mW)</th>
<th>$f_{\text{rep}}$ (GHz)</th>
<th>$t_{\text{pulse}}$ (ps)</th>
<th>$P_{\text{peak}}$ (W)</th>
</tr>
</thead>
<tbody>
<tr>
<td>53.2</td>
<td>9.2</td>
<td>2.91</td>
<td>1.74</td>
</tr>
<tr>
<td>10.1</td>
<td>18.2</td>
<td>4.98</td>
<td>0.05</td>
</tr>
<tr>
<td>15.9</td>
<td>2.2</td>
<td>2.47</td>
<td>2.62</td>
</tr>
<tr>
<td>35.0</td>
<td>2.2</td>
<td>3.03</td>
<td>4.73</td>
</tr>
</tbody>
</table>